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(71) Applicant(s)

Degussa Aktiengesellschaft

(Incorporated in the Federal Republic of Germany)

Weissfrauenstrassee 9, D-60311, Frankfurt, Federal Republic of Germany

(72) Inventor(s)

Manfred Ettlinger Werner Hartmann Dieter Kerner Jürgen Meyer (51) INT CL⁶ C09C 3/12

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(74) Agent and/or Address for Service

Elkington and Fife

Prospect House, 8 Pembroke Road, SEVENOAKS, Kent, TN13 1XR, United Kingdom

(54) Surface-modified pyrogenically produced mixed oxides

(57) Surface-modified, pyrogenically produced mixed oxides which contain two or more components from the series comprising SiO_2 , Al_2O_3 , TiO_2 , ZrO_2 , Fe_2O_3 , Nb_2O_5 , V_2O_5 , WO_3 , SnO_2 , GeO_2 and were surface-modified with one or more compounds from the following groups:

Organosilanes of the types

(a) (RO)₃Si(C_nH_{2n+1}),

(b) $R'_x(RO)_vSi(C_nH_{2n+1})$,

(c) X₃Si(C_nH_{2n+1}),

(d) X2(R')Si(CnH2n+1),

(e) X(R')₂ Si(C_nH_{2n+1}),

(f) (RO)3Si(CH2)m-R',

(g) (R")x(RO)ySi(CH2)m-R',

(h) X₃Si(CH₂)_m-R',

(i) (R)X2Si(CH2)m-R',

(j) (R)2X Si(CH2)m-R'

(k) Silazanes of the type R'R2Si-N-SiR2R',

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(I) Cyclic polysiloxanes,

(m) Polysiloxanes and silicone oils.

Surface-modified, pyrogenically produced mixed oxides, a process for their preparation and the use thereof

The invention relates to surface-modified, pyrogenically produced mixed oxides, the process for their preparation and the use thereof.

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The invention provides surface-modified, pyrogenically produced mixed oxides which contain two or more components from the series comprising SiO₂, Al₂O₃, TiO₂, ZrO₂, Fe₂O₃, Nb₂O₅, V₂O₅, WO₃, SnO₂, GeO₂ and were surface-modified with one or more compounds from the following groups:

- (a) Organosilanes of the type $(RO)_3Si(C_nH_{2n+1})$ R = alkyl, such as, for example, methyl-, ethyl-, n-propyl-, i-propyl-, butyl-
- n = 1 20
 - (b) Organosilanes of the type $R'_{x}(RO)_{y}Si(C_{n}H_{2n+1})$ R = alkyl, such as, for example, methyl-, ethyl-, n-propyl-, i-propyl-, butyl-
- R' = alkyl, such as, for example, methyl-, ethyl-, n-propyl-, i-propyl-, butyl-

n = 1 - 20

x+y = 3

x = 1,2

y = 1,2

- (c) Halogenorganosilanes of the type $X_3Si(C_nH_{2n+1})$ X = Cl, Br
 - n = 1 20

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(d) Halogenorganosilanes of the type X_2(R') Si(C_nH_{2n+1})
      X = C1, Br
      R' = alkyl,
                       such as, for example, methyl-, ethyl-,
                       n-propyl-, i-propyl-, butyl-
     n = 1 - 20
(e) Halogenorganosilanes of the type X(R')_2Si(C_nH_{2n+1})
     X = Cl, Br
     R' = alkyl, such as, for example, methyl-, ethyl-,
                       n-propyl-, i-propyl-, butyl-
     n = 1 - 20
(f) Organosilanes of the type (RO)<sub>3</sub>Si(CH<sub>2</sub>)<sub>m</sub>-R'
     R = alkyl, such as methyl-, ethyl-, propyl-
     m = 0, 1 - 20
     R' = methyl-, aryl (e.g. -C_6H_5, substituted phenyl
            radicals)
            -C_4F_9, OCF_2-CHF-CF_3, -C_6F_{13}, -O-CF_2-CHF_2
            -NH_2, -N_3, -SCN, -CH=CH_2,
            -OOC(CH_3)C = CH_2
            -OCH<sub>2</sub>-CH(O)CH<sub>2</sub>
            -NH-CO-N-CO-(CH<sub>2</sub>)<sub>5</sub>
            -NH-COO-CH_3, -NH-COO-CH_2-CH_3, -NH-(CH_2)_3Si(OR)_3
            -S_x-(CH<sub>2</sub>)<sub>3</sub>Si(OR)<sub>3</sub>
     Organosilanes of the type (R")<sub>x</sub>(RO)<sub>v</sub>Si(CH<sub>2</sub>)<sub>m</sub>-R'
                    x+y = 2
     R" = alkyl
                       x = 1,2
                       y = 1,2
                       m = 0.1 \text{ to } 20
     R' = methyl-, aryl (e.g. -C_6H_5, substituted phenyl
            radicals)
            -C_4F_9, -OCF_2-CHF-CF<sub>3</sub>, -C_6F_{13}, -O-CF_2-CHF<sub>2</sub>
            -NH_2, -N_3, -SCN, -CH=CH_2,
            -OOC(CH_3)C = CH_2
            -OCH2-CH(O)CH2
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-NH-CO-N-CO-(CH₂)₅

 $-S_x$ -(CH₂)₃Si(OR)₃

 $-NH-COO-CH_3$, $-NH-COO-CH_2-CH_3$, $-NH-(CH_2)_3Si(OR)_3$

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R = alkyl

m = 0, 1 - 20

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Halogenorganosilanes of the type X<sub>3</sub>Si(CH<sub>2</sub>)<sub>m</sub>-R'
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            X = C1, Br
            m = 0, 1 - 20
            R' = methyl-, aryl (e.g. -C_6H_5, substituted phenyl
                   radicals)
                   C_4F_9, -OCF_2-CHF-CF<sub>3</sub>, -C_6F_{13}, -O-CF_2-CHF<sub>2</sub>
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                   -NH_2, -N_3, -SCN, -CH=CH_2,
                   -OOC(CH_3)C = CH_2
                   -OCH<sub>2</sub>-CH(O)CH<sub>2</sub>
                   -NH-CO-N-CO-(CH_2)_5
                   -NH-COO-CH<sub>3</sub>, -NH-COO-CH<sub>2</sub>-CH<sub>3</sub>, -NH-(CH<sub>2</sub>)<sub>3</sub>si(OR)<sub>3</sub>
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                   -S_x-(CH<sub>2</sub>)<sub>3</sub>Si(OR)<sub>3</sub>
          Halogenorganosilanes of the type (R)X_2Si(CH_2)_m-R'
            X = Cl, Br
            R = alkyl, such as methyl-, ethyl-, propyl-
20
            m = 0, 1 - 20
            R' = methyl-, aryl (e.g. -C_6H_5, substituted phenyl)
                   radicals)
                   -C_4F_9, -OCF_2-CHF-CF<sub>3</sub>, -C_6F_{13}, -O-CF<sub>2</sub>-CHF<sub>2</sub>
                   -NH_2, -N_3, -SCN, -CH=CH_2,
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                   -OOC(CH_3)C = CH_2
                   -OCH<sub>2</sub>-CH(O)CH<sub>2</sub>
                   -NH-CO-N-CO-(CH<sub>2</sub>)<sub>5</sub>
                   -NH-COO-CH_3, -NH-COO-CH_2-CH_3, -NH-(CH_2)_3Si(OR)_3,
                    where R may be = methyl-, ethyl-, propyl-, butyl-
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                   -S_x-(CH_2)_3Si(OR)_3, where R may be = methyl-,
                    ethyl-, propyl-, butyl-
          Halogenorganosilanes of the type (R)2X Si(CH2)m-R'
           X = C1, Br
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$$R'' = \text{methyl-, aryl (e.g. } -C_6H_5, \text{ substituted phenyl radicals})$$

$$-C_4F_9, -OCF_2-CHF-CF_3, -C_6F_{13}, -O-CF_2-CHF_2$$

$$-NH_2, -N_3, -SCN, -CH=CH_2,$$

$$-OOC (CH_3) C=CH_2$$

$$-OCH_2-CH (O) CH_2$$

$$-NH-CO-N-CO-(CH_2)_5$$

$$-NH-COO-CH_3, -NH-COO-CH_2-CH_3, -NH-(CH_2)_3Si (OR)_3$$

$$-S_x-(CH_2)_3Si (OR)_3$$

(k) Silazanes of the type $R'R_2Si-N-SiR_2R'$

R = alkyl, R' = alkyl, vinyl

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- (1) Cyclic polysiloxanes of the type D 3, D 4, D 5, where D 3, D 4 and D 5 mean cyclic polysiloxanes with 3, 4 or 5 units of the type -O-Si(CH₃)₂-.
- For example, octamethylcyclotetrasiloxane = D 4

(m) Polysiloxanes and silicone oils of the type

- R = alkyl, such as C_nH_{2n+1} , where n is = 1 to 20, aryl, such as phenyl- and substituted phenyl radicals, $(CH_2)_n-NH_2, H$
- R' = alkyl, such as C_nH_{2n+1} , where n is = 1 to 20, aryl, such as phenyl- and substituted phenyl radicals, $(CH_2)_n-NH_2$, H
 - R'' = alkyl, such as C_nH_{2n+1} , where n is = 1 to 20, aryl, such as phenyl- and substituted phenyl radicals, $(CH_2)_n-NH_2$, H
- 10 R''' = alkyl, such as C_nH_{2n+1} , where n is =1 to 20, aryl, such as phenyl- and substituted phenyl radicals, $(CH_2)_n-NH_2, \ H$

The invention also provides a process for the preparation of 15 the surface-modified, pyrogenically produced mixed oxides according to the invention, which is characterised in that two or more metal chlorides from the series comprising SiCl₄, AlCl₃, TiCl₄, ZrCl₄, FeCl₃, NbCl₅, VOCl₃, WOCl₄, WCl₆, SnCl, and GeCl, are evaporated together or separately, 20 transferred together with an inert gas, for example, nitrogen, into the mixing chamber of a known burner, mixed there with hydrogen, air and/or oxygen, the multi-component mixture is burned in a reaction chamber, the solid mixed oxides are then separated from the gaseous reaction products 25 and freed from adhering hydrogen chloride optionally in moist air, and the pyrogenically produced mixed oxides are charged to a suitable mixing vessel, the mixed oxides are sprayed, with intensive mixing, optionally initially with water and subsequently with the surface-modifying reagent or 30 the mixture of several surface-modifying reagents, mixed again for 15 to 30 minutes and subsequently heat-treated at a temperature of 100 to 400°C for a period of 1 to 6 hours.

The water used may be acidified with an acid, for example,

35 hydrochloric acid, to a pH of 7 to 1. The surface-modifying
reagent used may be dissolved in a suitable solvent such as,
for example, ethanol. The mixing and/or heat treatment may

be carried out in a protectiv gas atmosphere such as, for example, nitrogen.

The invention also provides a process for the preparation of 5 the surface-modified, pyrogenically produced mixed oxides according to the invention, which is characterised in that two or more metal chlorides from the series comprising SiCl₄, AlCl₃, TiCl₄, ZrCl₄, FeCl₃, NbCl₅, VOCl₃, WOCl₄, WCl₆, SnCl₄ and GeCl₄ are evaporated together or separately, 10 transferred together with an inert gas, for example, nitrogen, into the mixing chamber of a known burner, mixed there with hydrogen, air and/or oxygen, the multi-component mixture is burned in a reaction chamber, the solid mixed oxides are then separated from the gaseous reaction products 15 and freed from adhering hydrogen chloride optionally in moist air, and mixed as homogeneously as possible with organohalogen silanes with the exclusion of oxygen, the mixture together with small quantities of water vapour and optionally together with an inert gas is heated to 20 temperatures from 200 to 800°C, preferably 400 to 600°C, in the continuous co-current process in a treatment chamber taking the form of an upright tubular furnace, the solid and gaseous reaction products are separated from each other, the solid products are optionally de-acidified and dried.

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The invention also provides for the use of the surfacemodified, pyrogenically produced mixed oxide according to the invention as

- reinforcing filler in silicone rubber and rubber
- 30 charge stabiliser and free-flow agent in toner powders
 - free-flow agent
 - anti-blocking agent, for example, in films
 - UV blocker, for example, in cosmetics
 - thickener, for example, in lacquers.

Exampl s

Examples for the preparation of mixed oxides

- 5 The metal chlorides 1 and 2 are volatilised in separate evaporators and the chloride vapours are fed into the mixing chamber of a burner by means of nitrogen. There they are mixed with hydrogen and dried air and/or oxygen and burned in a reaction chamber. In the coagulation zone the reaction products are cooled to approximately 110°C and the resulting mixed oxides are subsequently separated with a filter. Adhering chloride is removed by treating the powders with moist air at temperatures between 500 and 700°C.
- 15 The reaction conditions and the product properties for the various mixed oxides are summarised in Table 1.

Examples for the preparation of surface-modified mixed oxides

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The reaction conditions and stoichiometric conditions for the surface modification may be derived from Table 2. The physical-chemical data are summarised in Table 3.

Reaction conditions and product properties of some mixed oxides Table 1:

Chloride content (%)	1.0	0.12	0.3	0.4	0.24	0.16	9.0	0.15
Loss on ignition (%)	0.6	2.9	1.2	1.7	6.0	7.0	1.1	6.0
Tamped density (g/l)	85	104	175	185	48	329	120	218
BET (m²/g)	95	179	53	46	121	47	72	65
Air (i/h)	3280	1300	3079	3079	2420	1276	3579	3080
H ₂ (J/h)	470	300	525	525	800	448	525	525
Metal chloride 2 (g/h)	TiC14 516	Sicl ₄ 778	TiCl4 1697	TiC14 1613	ZrCl4 135	Ticle 793	Tic14 1269	ZrCl4
Metal chloride 1 (g/h)	Sicl ₄ 50	AlCl, 126	FeC1,	Fecl ₃ 107	Sicl ₄ 1303	AlCl ₃ 188	AlCl ₃ 464	Tic14
Oxide 2 (wt. %)	TiO ₂ 92.5	SiO ₂ 85	TiO ₂ 98	TiO ₂ 93	2r0 ₂ 13	T10 ₂ 89	TiO ₂ 75	ZrO ₂
Oxide 1 (wt.%)	SiO ₂ 7.5	Al ₂ O ₃ 15	Fe ₂ O ₃	Fe ₂ O ₃	SiO ₂ 87	A1 ₂ 0 ₃	A1 ₂ 0 ₃ 25	TiO ₂
Mixed oxide example	T	2	3	4	5	9	7	æ

Table 2

E.g.	Name	Mixed oxide	Modi- fying reagent*	Modi- fying reagent (g/100g mixed oxide)	Water quantity (g/100g mixed oxide)	Solvent quan- tity (g/100 g mixed oxde	Tempering time (h)	Tempering temperature (°C)
9	VT772	4	1	10	0	0	4	140
10	VT773	4	2	10	0	0	2	120
11	VT774	4	3	10	0	0	2.5	250
12	VT816	3	1	10	0	0	3	180
13	VT817	3	2	10	0	0	2	120
14	VT818	3	3	10	0	О	2.5	250
15	VT775	2	1	20	0	0	4	140
16	VT776	2	2	16	0	0	2	120
17	VT777	2	3	15	0	0	2	250
18	VT819	8	1	10	0	0	4	180
19	VT820	8	2	10	0	0	2	120
20	VT821	8	3	10	0	0	2.5	250
21	VT900	4	2	12	5	0	2.5	140
22	VT901	3	2	10	0	10**	2.5	140
23	VT747	6	2	5	0	0	2	120
24	VT748	6	2	10	0	0	2	120
25	VT749	6	4	10	0	0	2	120
26	VT750	7	2	10	0	0	2	120
27	VT751	7	4	10	0	0	2	120
28	VT719	5	1	10	5	0	3	130
29	VT734	1	3	10	0	0	2	250

* 1 = Hexamethyldisilazane = $(CH_3)_3Si-NH-Si(CH_3)_3$ 2 = Trimethoxy-octyl-silane = $(CH_3O)_3Si-(CH_2)_7-CH_3$ 3 = Dimethylpolysiloxane = $HO-\begin{pmatrix} CH_3 \\ i \\ Si-O \end{pmatrix}$ - H

4 = Trimethoxy-propyl-silane = (CH₃O)₃Si-CH₂-CH₂-CH₃

Table 3

Example	Name	Spec. surface area BET (m²/g)	Tamped density (g/l)	Loss on drying (%)	Loss on ignition (%)	рН	Carbon content (%)
9	VT772	40	269	0.0	1.3	6.4	0.5
10	VT773	36	280	0.1	4.7	3.4	3.6
11	VT774	27	301	0.2	3.9	3.4	2.7
12	VT816	45	258	0.4	1.1	7.5	0.5
13	VT817	39	288	0.7	3.9	3.4	3.5
14	VT818	32	292	0.0	3.6	3.6	2.9
15	VT775	124	127	0.5	3.4	6.6	1.7
16	VT776	111	136	1.0	9.5	4.2	5.8
17	VT777	101	136	0.9	4.7	4.2	2.9
18	VT819	51	245	0.5	0.7	9.0	0.4
19	VT820	45	275	0.0	4.4	4.0	3.6
20	VT821	35	275	0.0	2.3	4.1	2.5
21	VT900	34	275	0.1	4.9	3.5	3.9
22	VT901	38	282	0.6	4.0	3.6	3.6
23	VT747	31	396	0.2	1.7	3.7	2.0
24	VT748	23	409	0.3	4.8	4.0	3.9
25	VT749	26	402	0.3	2.3	4.1	1.8
26	VT750	56	161	0.3	16.8	3.8	3.9
27	VT751	55	162	0.2	2.7	4.1	2.0
28	VT719	60	60	0.1	1.1	6.4	1.3
29	VT734	74	114	0.5	2.5	4.2	2.5

Patent claims

 Surface-modified, pyrogenically produced mixed oxides which contain two or more components from the series comprising SiO₂, Al₂O₃, TiO₂, ZrO₂, Fe₂O₃, Nb₂O₅, V₂O₅, WO₃, SnO₂, GeO₂ and were surface-modified with one or more compounds from the following groups:

(a) Organosilanes of the type $(RO)_3Si(C_nH_{2n+1})$ R = alkyl

n = 1 - 20

(b) Organosilanes of the type $R'_{x}(RO)_{y}Si(C_{n}H_{2n+1})$ R = alkyl

R' = alkyl

n = 1 - 20

x+y = 3

x = 1, 2

y = 1,2

(c) Halogenorganosilanes of the type

 $X_3Si(C_nH_{2n+1})$

X = Cl, Br

n = 1 - 20

(d) Halogenorganosilanes of the type

 $X_2(R')$ Si(C_nH_{2n+1})

X = Cl, Br

R'= alkyl

n = 1 - 20

(e) Halogenorganosilanes of the type

 $X(R')_2Si(C_nH_{2n+1})$

X = Cl, Br

R' = alkyl

n = 1 - 20

(f) Organosilanes of the type (RO)₃Si(CH₂)_m-R'

R = alkyl,

m = 0, 1 - 20

R' = methyl-, aryl (e.g. -C₆H₅, substituted
 phenyl radicals)

 $-C_4F_9$, $OCF_2-CHF-CF_3$, $-C_6F_{13}$, $-O-CF_2-CHF_2$

 $-NH_2$, $-N_3$, -SCN, $-CH=CH_2$,

 $-OOC(CH_3)C = CH_2$

<u>.</u>

$$-OCH_2-CH(O)CH_2$$

$$-NH-CO-N-CO-(CH_2)_5$$

$$-NH-COO-CH_3, -NH-COO-CH_2-CH_3, -NH-(CH_2)_3Si(OR)_3$$

$$-S_x-(CH_2)_3Si(OR)_3$$

(g) Organosilanes of the type $(R")_x(RO)_ySi(CH_2)_m-R'$ R" = alkyl x+y = 2 x = 1,2 y = 1,2 m = 0,1 to 20 $R' = methyl-, aryl (e.g. -C_6H_5, substituted phenyl radicals)$ $-C_4F_9, -OCF_2-CHF-CF_3, -C_6F_{13}, -O-CF_2-CHF_2$ $-NH_2, -N_3, -SCN, -CH=CH_2,$ $-OOC(CH_3)C = CH_2$ $-OCH_2-CH(O)CH_2$ $-NH-CO-N-CO-(CH_2)_5$ $-NH-COO-CH_3, -NH-COO-CH_2-CH_3, -NH-(CH_2)_3Si(OR)_3$

 $-S_x-(CH_2)_3Si(OR)_3$

(h) Halogenorganosilanes of the type X₃Si(CH₂)_m-R'

X = Cl, Br

m = 0, 1 - 20

R' = methyl-, aryl (e.g. -C₆H₅, substituted phenyl radicals)

-C₄F₉, -OCF₂-CHF-CF₃, -C₆F₁₃, -O-CF₂-CHF₂

-NH₂, -N₃, -SCN, -CH=CH₂,

-OCC(CH₃)C = CH₂

-OCH₂-CH(O)CH₂

-NH-CO-N-CO-(CH₂)₅

-NH-COO-CH₃, -NH-COO-CH₂-CH₃, -NH-(CH₂)₃Si(OR)₃

-S_x-(CH₂)₃Si(OR)₃

(i) Halogenorganosilanes of the type (R) X₂Si(CH₂)_m-R'
X = Cl, Br
R = alkyl,
m = 0, 1 - 20

(j) Halogenorganosilanes of the type (R)₂X Si(CH₂)_m-R'

X = Cl, Br

R = alkyl

m = 0, 1 - 20

R' = methyl-, aryl (e.g. $-C_6H_5$, substituted phenyl radicals)

$$-C_4F_9$$
, $-OCF_2$ -CHF-CF₃, $-C_6F_{13}$, $-O-CF_2$ -CHF₂

$$-NH_2$$
, $-N_3$, $-SCN$, $-CH=CH_2$,

$$-NH-CO-N-CO-(CH_2)_5$$

 $-NH-COO-CH_3$, $-NH-COO-CH_2-CH_3$, $-NH-(CH_2)_3Si(OR)_3$

$$-S_x-(CH_2)_3Si(OR)_3$$

(k) Silazanes of the type R'R₂Si-N-SiR₂R' | H

$$R = alkyl,$$

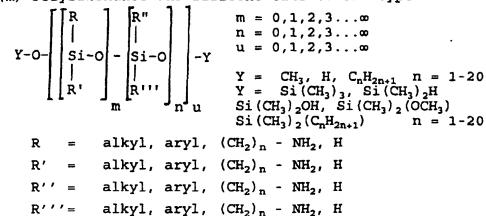
R' = alkyl, vinyl

(1) Cyclic polysiloxanes of the type D 3, D 4, D 5, e.g. octamethylcyclotetrasiloxane = D 4

$$H_3C$$
 O
 CH_3
 CH_3
 CH_3
 CH_3
 CH_3
 CH_3
 CH_3

(m) Polysiloxanes and silicone oils of the type

÷.



- 2. A process for the preparation of surface-modified, pyrogenically produced mixed oxides according to claim 1, characterised in that two or more metal chlorides from the series comprising SiCl₄, AlCl₃, TiCl₄, ZrCl₄, FeCl₃, NbCl₅, VOCl₃, WOCl₄, WCl₆, SnCl₄ and GeCl₄, are evaporated together or separately, transferred together with an inert gas, for example, nitrogen, into the mixing chamber of a known burner, mixed there with hydrogen, air and/or oxygen, the multi-component mixture is burned in a reaction chamber, the solid mixed oxides are then separated from the gaseous reaction products and freed from adhering hydrogen chloride optionally in moist air, and the pyrogenically produced mixed oxides are charged to a suitable mixing vessel, the mixed oxides are sprayed, with intensive mixing, optionally initially with water and subsequently with the surface-modifying reagent or the mixture of several surface-modifying reagents, mixed again for 15 to 30 minutes and subsequently heat-treated at a temperature of 100 to 400°C for a period of 1 to 6 hours.
- 3. A process for the preparation of surface-modified, pyrogenically produced mixed oxides according to claim 1, characterised in that two or more metal chlorides from the series comprising SiCl₄, AlCl₃, TiCl₄, ZrCl₄, FeCl₃, NbCl₅, VOCl₃, WOCl₄, WCl₆, SnCl₄ and GeCl₄ are evaporated together

or separately, transferred together with an inert gas, for example, nitrogen, into the mixing chamber of a known burner, mixed there with hydrogen, air and/or oxygen, the multi-component mixture is burned in a reaction chamber, the solid mixed oxides are then separated from the gaseous reaction products and freed from adhering hydrogen chloride optionally in moist air, and mixed as homogeneously as possible with organohalogen silanes with the exclusion of oxygen, and the mixture together with small quantities of water vapour and optionally together with an inert gas is heated to temperatures from 200 to 800°C, preferably 400 to 600°C, in the continuous cocurrent process in a treatment chamber taking the form of an upright tubular furnace, the solid and gaseous reaction products are separated from each other, the solid products are optionally de-acidified and dried.

- 4. The use of the surface-modified, pyrogenically produced mixed oxide according to claim 1 as
 - reinforcing filler in silicone rubber and rubber
 - charge stabiliser and free-flow agent in toner powders
 - free-flow agent
 - anti-blocking agent, for example, in films
 - UV blocker, for example, in cosmetics
 - thickener, for example, in lacquers.
- 5. Surface modified, pyrogenically produced mixed oxides substantially as hereinbefore described with particular reference to the examples.
- 6. A process for the production of surface modified, pyrogenically produced mixed oxides substantially as hereinbefore described with particular reference to the examples.





Application No: Claims searched:

GB 9600301.7

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Examiner:

C.A.Clarke

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Patents Act 1977 Search Report under Section 17

Databases searched:

UK Patent Office collections, including GB, EP, WO & US patent specifications, in:

UK CI (Ed.O): C1A (AVF1,AVF3)

Int Cl (Ed.6): C09C 3/12

Other:

Documents considered to be relevant:

Category	Identity of document and relevant passage				
X	GB 2056995 A	DEGUSSA see claim1 and p2 line 11-12	1		
x	GB 1592802	UNION CARBIDE see p9 lines 22-42	1		
x	GB 1371219	DEUTSCHE GOLD UND SILBER see Example 8	1		
x	GB 1371218	DEUTSCHE GOLD UND SILBER see example 2	1		
x	EP 0417866 A	SHISEIDO see p9 line 55 - p10 line 7	1		
x	EP 0212870 A	SHISEIDO see p26 lines 11-28	1		

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X Document indicating lack of novelty or inventive step
 Y Document indicating lack of inventive step if combined with one or more other documents of same category.

A Document indicating technological background and/or state of the ant.
 P Document published on or after the declared priority date but before the filing date of this invention.

Member of the same patent family

E Patent document published on or after, but with priority date earlier than, the filing date of this application.